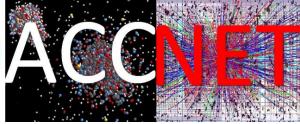


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http://accnet.lal.in2p3.fr

accelerator physics, optics and instrumentation challenges

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with

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optics needs

in front of plasma

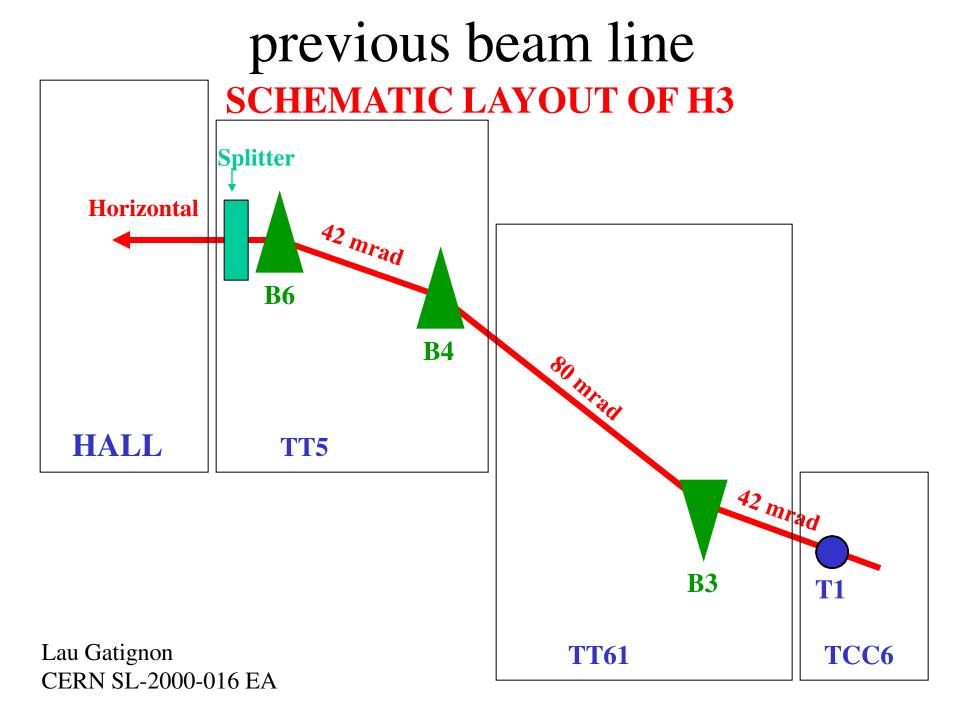
• [adjustable] momentum compaction (R₅₆) ~ 1-5 m ?

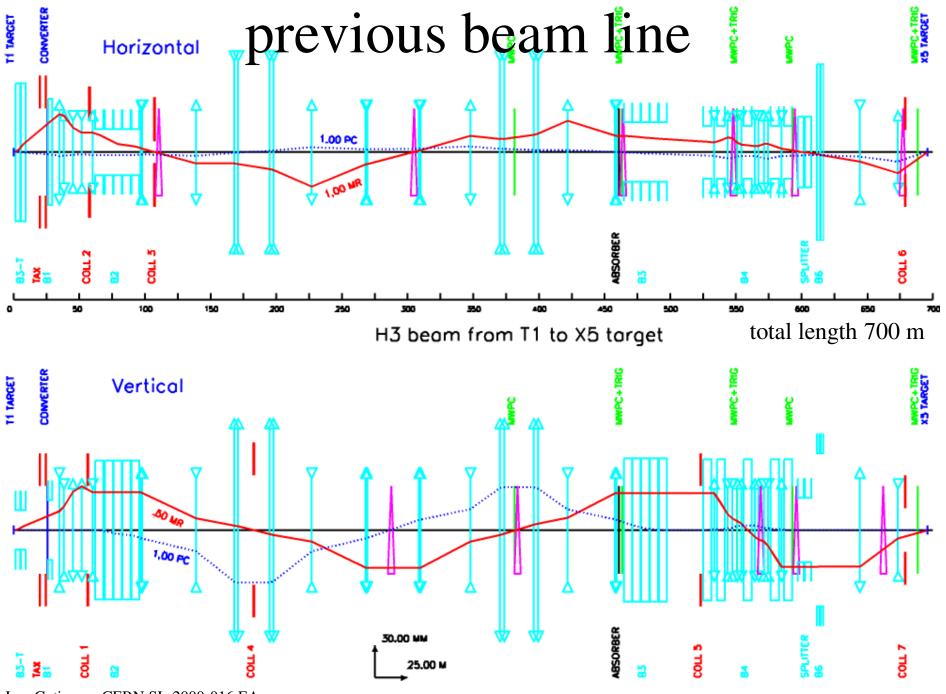
at plasma

- zero dispersion
- small beta function, but not smaller than plasma length (say ~5 m or more)

behind plasma

- "spectrometer" with large dispersion;100 MeV change is ~2x10⁻⁴ : dispersion of 1 m would lead to 0.2 mm displacement of particles with 100 MeV offset
- image point, 180 degrees phase advance from plasma (include or not include plasma focusing?); matching of outgoing optics for plasma effect?





Lau Gatignon, CERN SL-2000-016 EA

from old to new beam line total length 700 m

in previous optics:

~zero dispersion from 500 m onward

"cell length" ~ 100 m

for plasma acceleration plasma around 500 m point?! (or earlier?)

assume 90 degree phase advance / cell consider FODO optics with **cell length 2L~50 m** $\beta_{max} \sim 85 \text{ m}, \beta_{min} \sim 15 \text{ m}$ quadrupole focal strength: $1/f \sim 0.057 \text{ m}^{-1}$ **pole-tip radius a=2 cm, magnet length 4 m** $\rightarrow B_{tip} \sim 1.65 \text{ Tesla}, OK$ may need a special focusing optics to reach $\beta^* \sim 5$ m at plasma

 $D \sim \theta_B 4L = 1 \text{ m} \rightarrow I_B = 10 \text{ m with } B = 1.5 \text{ T}$ would suffice

beam parameters

	"LHC" bunch	TOTEM bunch	"LHC" lead bunch
ion	p+	p+	²⁰⁸ Pb ⁸²⁺
energy / nucleon [GeV]	450	450	177.4
ions/bunch [10 ¹⁰]	11.5	3-6	0.007
rms longitudinal emittance/Z [eVs]	0.06	0.02	0.06
rms bunch length [ns]	<0.5	<0.3	0.33
relative rms energy spread [10-3]	0.3	<0.18	0.4
rms transverse emittance [µm]	3.5	1.0	1.4
rms beam size at β^* ~5 m	200 µm	100 µm	200 µm

 $1 \text{ ns} = 30 \text{ cm}, 3 \text{ x} 10^{-4} \text{ ns} = 100 \ \mu\text{m}$

1 bunch every ~30 s or several bunches every 30 s

getting shorter or "better" bunches

- RF bunch compression in beam line
- "shaping" the distribution e.g. steep edge
- bunch rotation via change in RF voltage or momentum compaction prior to extraction
- x(y)-z 4/6-D emittance exchange transformation
- creating microstructure at plasma wavelength
- combination of the above

RF bunch compression in line minimum bunch length with full compression

 $\sigma_{z,f}$ = R₅₆ $\sigma_{\delta,0}$

(1) require $\sigma_{z,f}$ =200 µm, take $\sigma_{\delta,0}$ ~2x10⁻⁴

 \rightarrow R₅₆ < 1 m OK

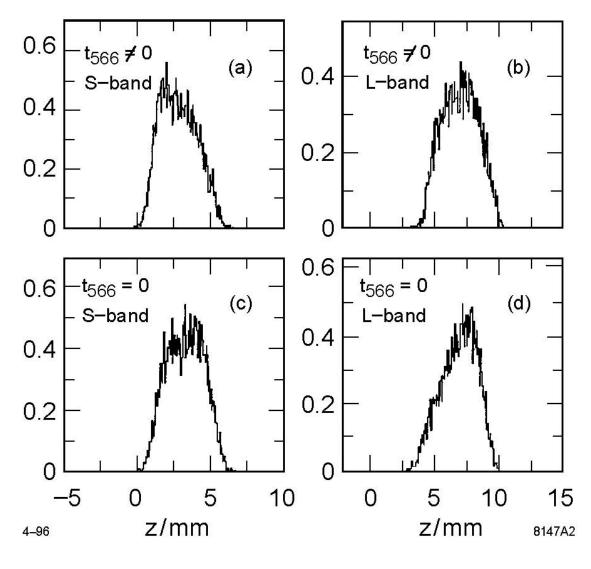
 $V_{rf} f_{rf} = E c/e/R_{56}/(2\pi)$ for full compression assume $f_{rf} = 3 \text{ GHz} \rightarrow V_{rf} > 7 \text{ GV}$

(2) require $\sigma_{z,f}$ = 1 mm, take $\sigma_{\delta,0}$ ~2x10⁻⁴

 \rightarrow R₅₆ < 5 m OK \rightarrow V_{rf} > 1.4 GV

with 30 MV/m gradient & 0.65 filling factor this would need ~75 m of 3-GHz linac

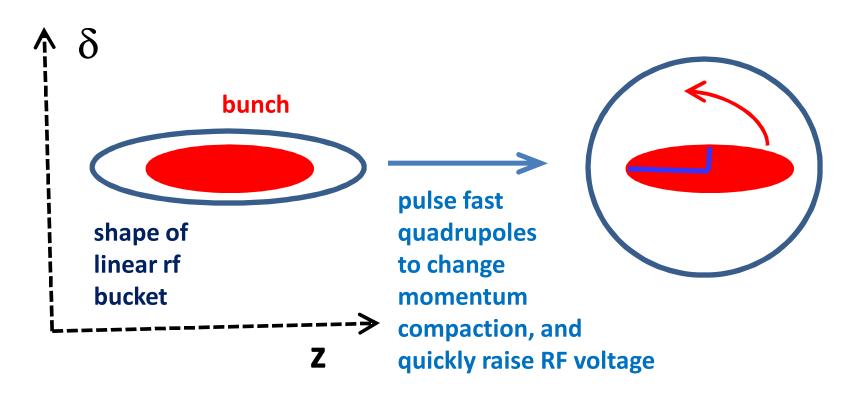
bunch shaping



modifications of the second order terms allow creating a sharp edge at the start or end of the bunch

> F. Zimmermann Simulation studies of the SLC Bunch Compressor, EPAC'96

bunch rotation prior to extraction



extract after ¼ synchrotron oscillation when bunch length is minimum

$$\sigma_{z,min} \approx 2 \sqrt{\frac{V_{RF,initial} \, \alpha_{c,new}}{V_{RF,new} \alpha_{c,initial}}} \sigma_{z,initial}$$

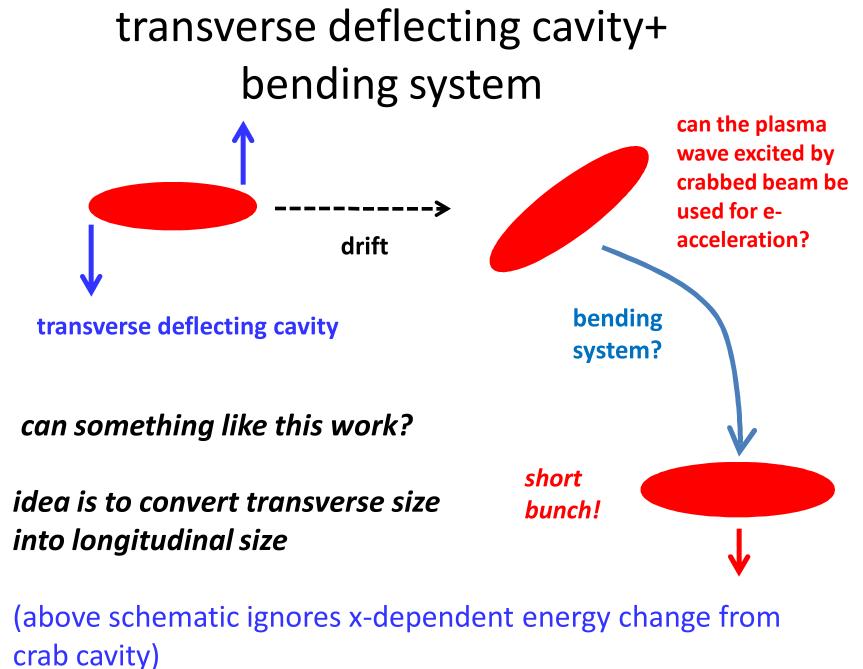
bunch length scales with the square root of pulsed momentum compaction factor

SPS initial momentum compaction $\alpha_{\rm c,initial} \sim 0.00186$

with new optics & additional magnet circuits we may hope for $\alpha_{\rm c,new}$ ~ 10⁻⁴

initial RF voltage ~ 7 MV may we "hope" for final RF voltage ~ 10x higher (70 MV) ??

 \rightarrow then expect compression by factor 2 x 10⁻¹ /Sqrt(10) ~ 0.06 ~ 1/16



or transverse crab cavity followed by "slit"?

generating microstructure

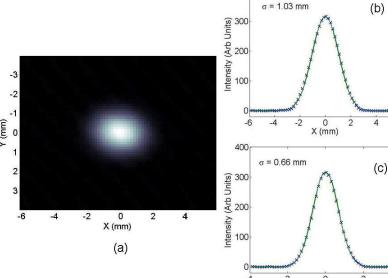
- microwave instability with high-Q resonator
 - energy modulation from plasma conditioner followed by bends

nano-stuctured chopper

schematic of a bunch with longitudinal microstructure [blue] superimposed on an original smooth bunch shape [red] —horizontal axis is time; vertical shows charge density

instrumentation

- beam position monitors along the line
- at spectrometer/image point we need a 2-D profile monitors (OTR or other screen, pixel detector, ...?)
- streak camera?
- or fast kicker for time resolution
 inside bunch?



OTR image of 150 GeV protons at the Tevatron, (V. Scarpine et al, 2006)

synchrotron
radiation from SC bend or plasma?

source, optics & instrumentation for e- beam

no work & no thinking done so far (by me at least)

- need space and location for e- injector
- need to match and inject into plasma
- need synchronization and alignment with p beam

some experience from LEP, SLC, CLIC, CTF-3

conclusions

- optics looks feasible; 50 m cell length, 1.65 T pole-tip field
- beam parameter sets
- several schemes for achieving moderate bunch compression or bunch shaping
- e- injector & e- optics to be looked at